

## EAST Search History

| Ref # | Hits | Search Query   | DBs   | Default Operator | Plurals | Time Stamp          |
|-------|------|--|---|------------------|---------|---------------------|
| S47   | 2    | "20060097266"  | US-PGPUB;<br>USPAT; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | ON      | 2008/11/14<br>14:07 |
| S48   | 1    | "20060097266" and plate  | US-PGPUB;<br>USPAT; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | ON      | 2008/11/14<br>14:07 |
| S49   | 67   | (sic or silicon near2 carbide) near10 increases \$5 near2 diameter   | US-PGPUB;<br>USPAT; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | ON      | 2008/11/19<br>23:18 |
| S50   | 38   | (sic or silicon near2 carbide) near10 increases \$5 near2 diameter and (sic or silicon near2 carbide) near10 (wafer or single near2 crystal \$6) | US-PGPUB;<br>USPAT; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | ON      | 2008/11/19<br>23:19 |
| S51   | 48   | (sic or silicon near2 carbide) near10 deposit \$5 near4 around   | US-PGPUB;<br>USPAT; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | ON      | 2008/11/19<br>23:23 |
| S52   | 37   | (shigehiro near2 nishino or kazutoshi near2 murata).in. and (sic or silicon near2 carbide)   | US-PGPUB;<br>USPAT; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | ON      | 2008/11/19<br>23:32 |
| S53   | 2941 | (ring or annular\$6) near10 (sic or silicon near2 carbide)   | US-PGPUB;<br>USPAT; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | ON      | 2008/11/19<br>23:33 |
| S54   | 65   | (ring or annular\$6) near10 (sic or silicon near2 carbide) near10 (vapor near2 deposit \$5 or cvd)   | US-PGPUB;<br>USPAT; EPO;<br>JPO;<br>DERWENT;<br>IBM_TDB | OR               | ON      | 2008/11/19<br>23:33 |

|     |     |  |   |    |    |                  |
|-----|-----|--|---|----|----|------------------|
| S55 | 100 | (sic or silicon near2 carbide) near15 single near2 crystal\$6 near15 deposit\$6 near16 polycrystal\$7  | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2008/11/19 23:34 |
| S56 | 135 | ("alpha." or alpha or "6h") near10 (sic or silicon near2 carbide) near2 (wafer or substrate) same (beta or ".beta." or "3c") near15 (sic or silicon near2 carbide) near6 (film or layer) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2008/11/19 23:34 |

11/20/08 10:47:20 AM  
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